## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Venkat Selvamanickam

Title: METALORGANIC CHEMICAL VAPOR DEPOSITION (MOCVD)

PROCESS AND APPARATUS TO PRODUCE MULTI-LAYER HIGH-TEMPERATURE SUPERCONDUCTING (HTS) COATED TAPE

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App. No.: 10/602,468 Filed: June 23, 2003

Examiner: Aaron Austin Group Art Unit: 1784

Atty. Dkt. No.: 1014-SP156-US Confirmation No.: 2661

Mail Stop AMENDMENT Commissioner for Patents PO Box 1450

Alexandria, VA 22313-1450

## REPLY TO FINAL OFFICE ACTION

## Dear Commissioner:

In response to the Final Office Action mailed July 21, 2011, please amend the aboveidentified application as follows:

Claim Amendments begin on page 2.

Remarks begin on page 5.

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